

What causes the fluctuations in $f_{\max}$ with respect to frequency?

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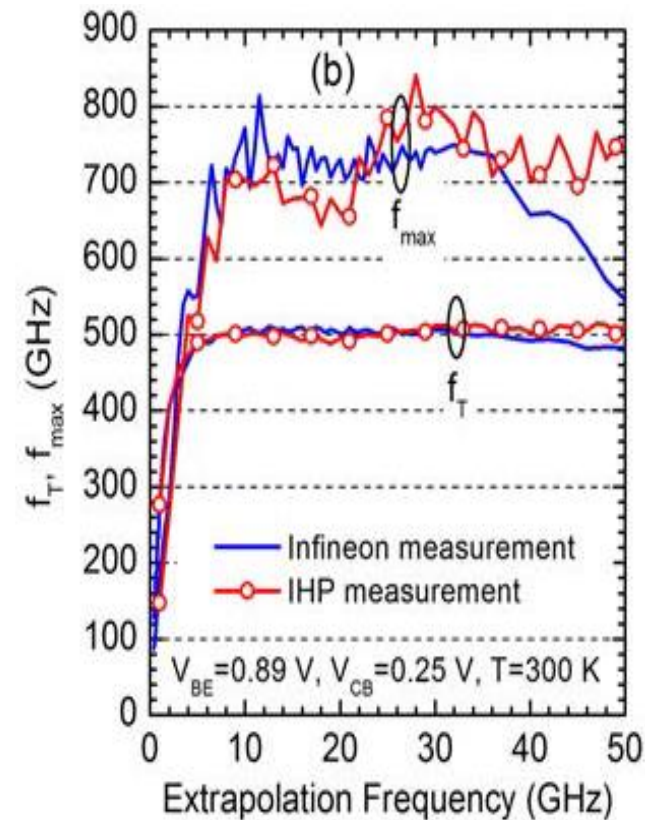
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Impact of test structure and probes on calibration ?

Impact of calibration/probes on FOM measurement

- f_{MAX} is a FOM that is difficult to measure : same device measured at IHP and Infineon

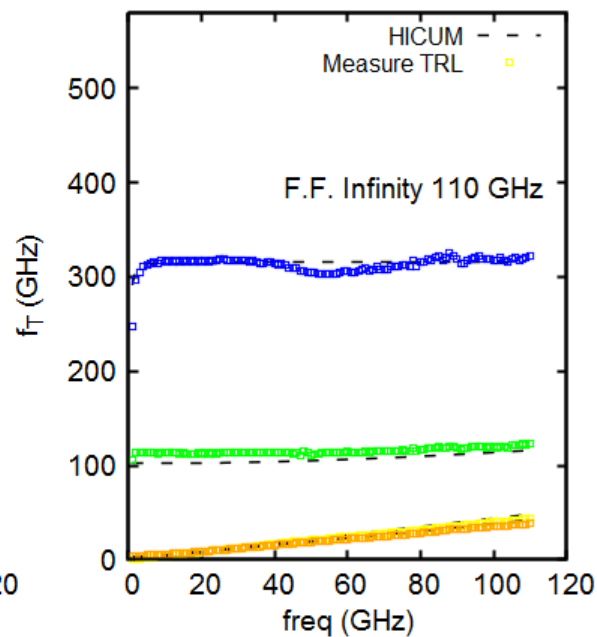
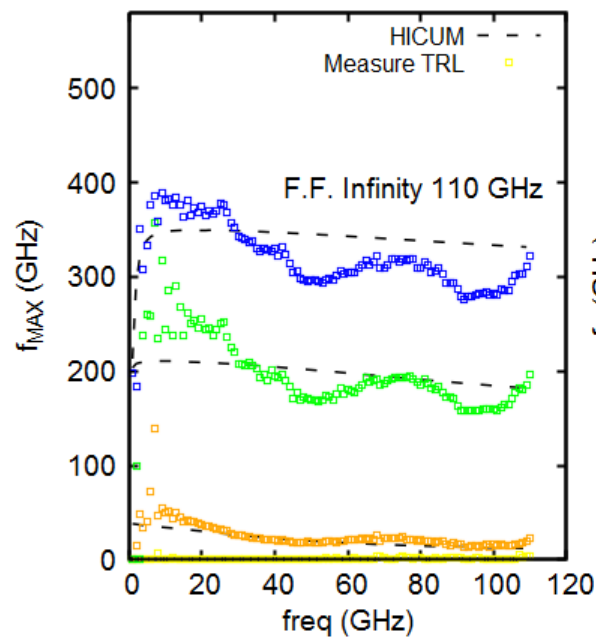


B. Heinemann *et al.*, « SiGe HBT with f_x/f_{max} of 505 GHz/720 GHz », in *2016 IEEE IEDM*, déc. 2016

Impact of test structure and probes on calibration ?

Impact of calibration/probes on FOM measurement

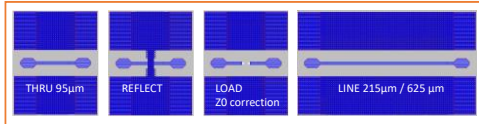
- f_{MAX} is a FOM that is difficult to measure : same device measured at IHP and Infineon
- What about our result on STMicroelectronics B55 technology



How to analyse the results ?

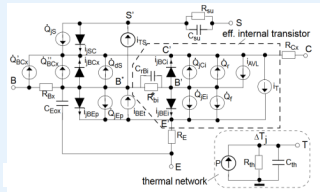
Impact of test structure and probes on calibration ?

Simulation methodology => reproduce the measurement procedure

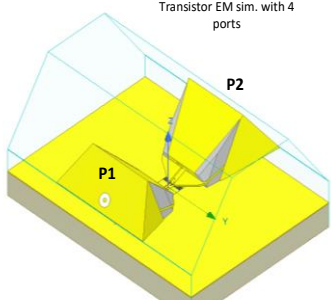


TRANSISTOR

EM sim. + SPICE
simulation



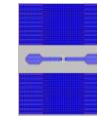
Transistor EM sim. with 4 ports



Transistor EM sim. with 4 ports

P2

**open /
short**



De-embedding
OS / SO

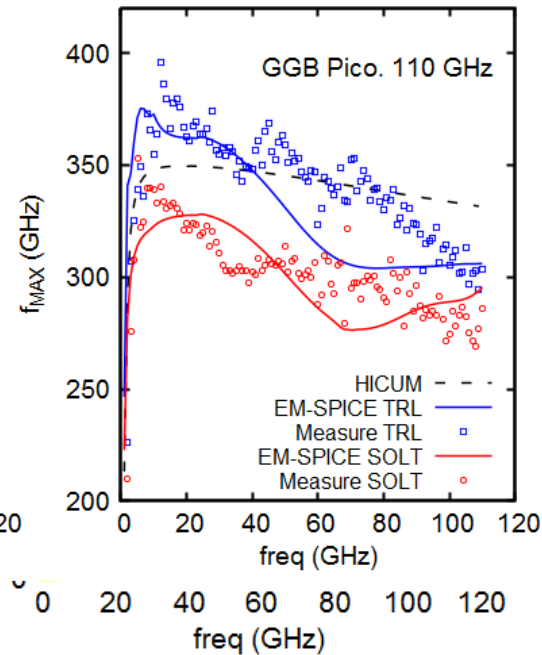
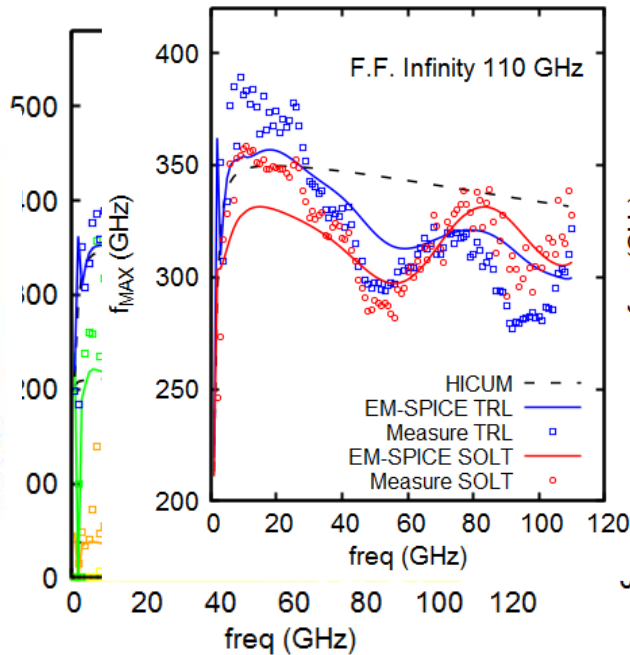
comparison

Does cal. + deemb. allows to recover intrinsic characteristics ?

Impact of test structure and probes on calibration ?

Impact of calibration/probes on FOM measurement

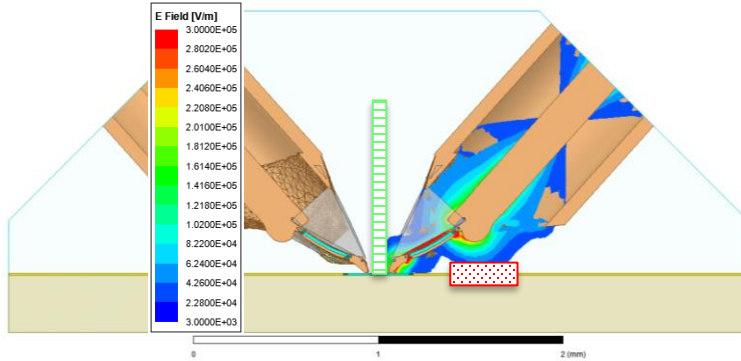
- ▶ f_{MAX} is a FOM that is sensitive to calibration accuracy
- ▶ Example of TRL calibration result on STMicroelectronics B55 technology



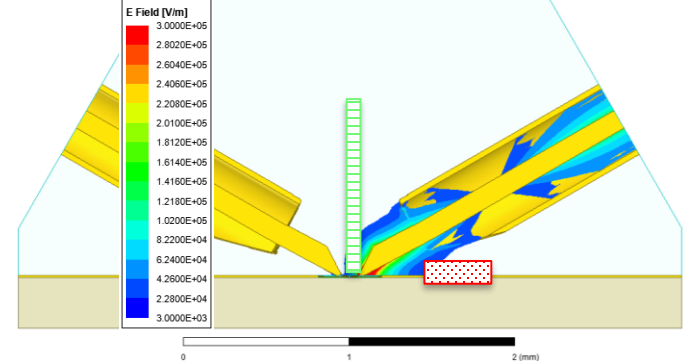
Impact of test structure and probes on calibration ?

Impact of calibration/probes on FOM measurement

Example of probe crosstalk with inter-probe distance of $\sim 140\mu\text{m}$

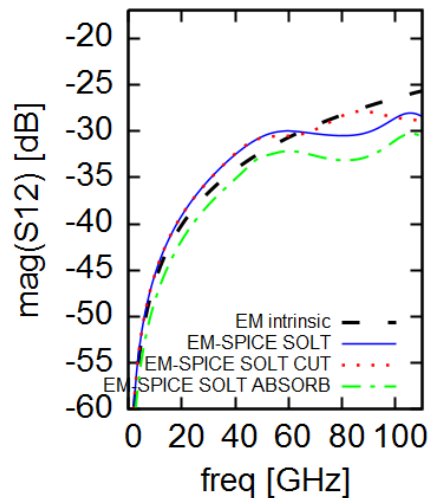


Infinity probe ($100\mu\text{m}$ pitch)
on a trans-open, freq = 60 GHz

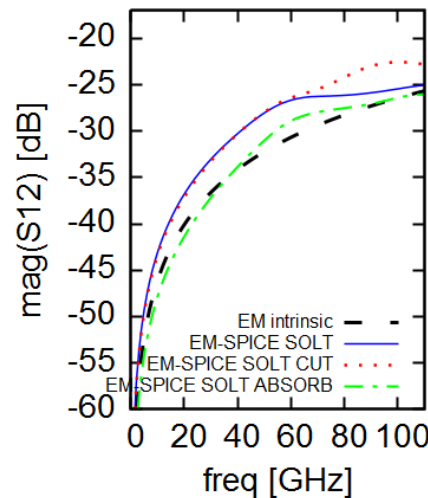


Pico-probe ($100\mu\text{m}$ pitch)
on a trans-open, freq = 60 GHz

F. F. Infinity 110 GHz



GGB Pico. 110 GHz



⇒ probe couplings has
a strong impact ! (not
corrected by SOLT /
TRL)



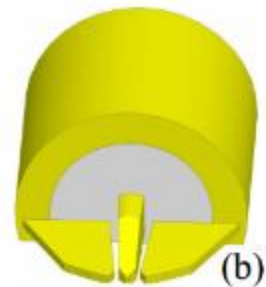
Where is the way out?

- All S-parameters above 30 GHz are wrong, that is to say, they are affected by not-corrected coupling
- How to solve the issue
 - New probes with appropriate test-structures
 - New calibration method with appropriate test-structures

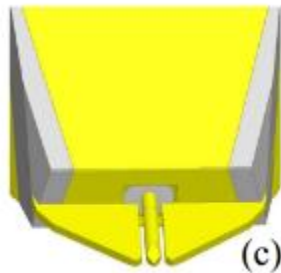
Impact of test structure and probes on calibration ?

Impact of calibration/probes on FOM measurement : measurement up to 500 GHz & discontinuities

- Advanced probe models are required to understand measurement imperfections

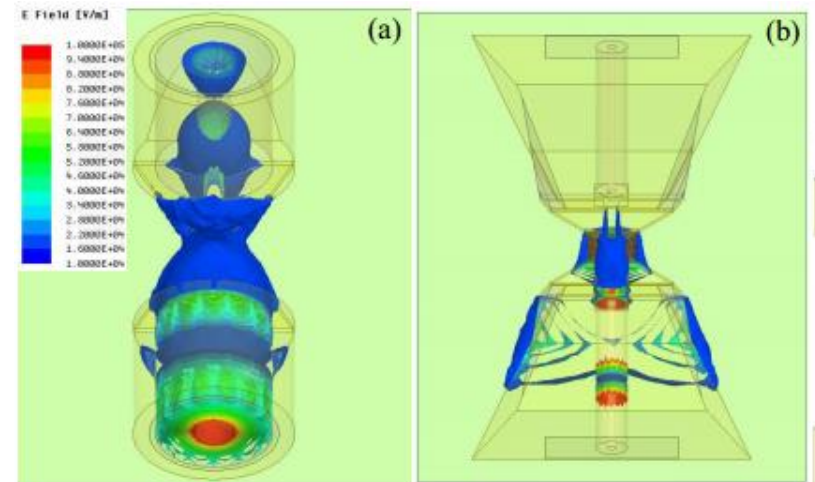
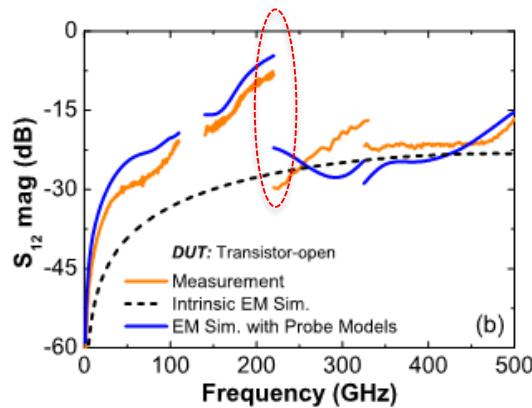


140-220 GHz



220-325 GHz

@ 220 GHz



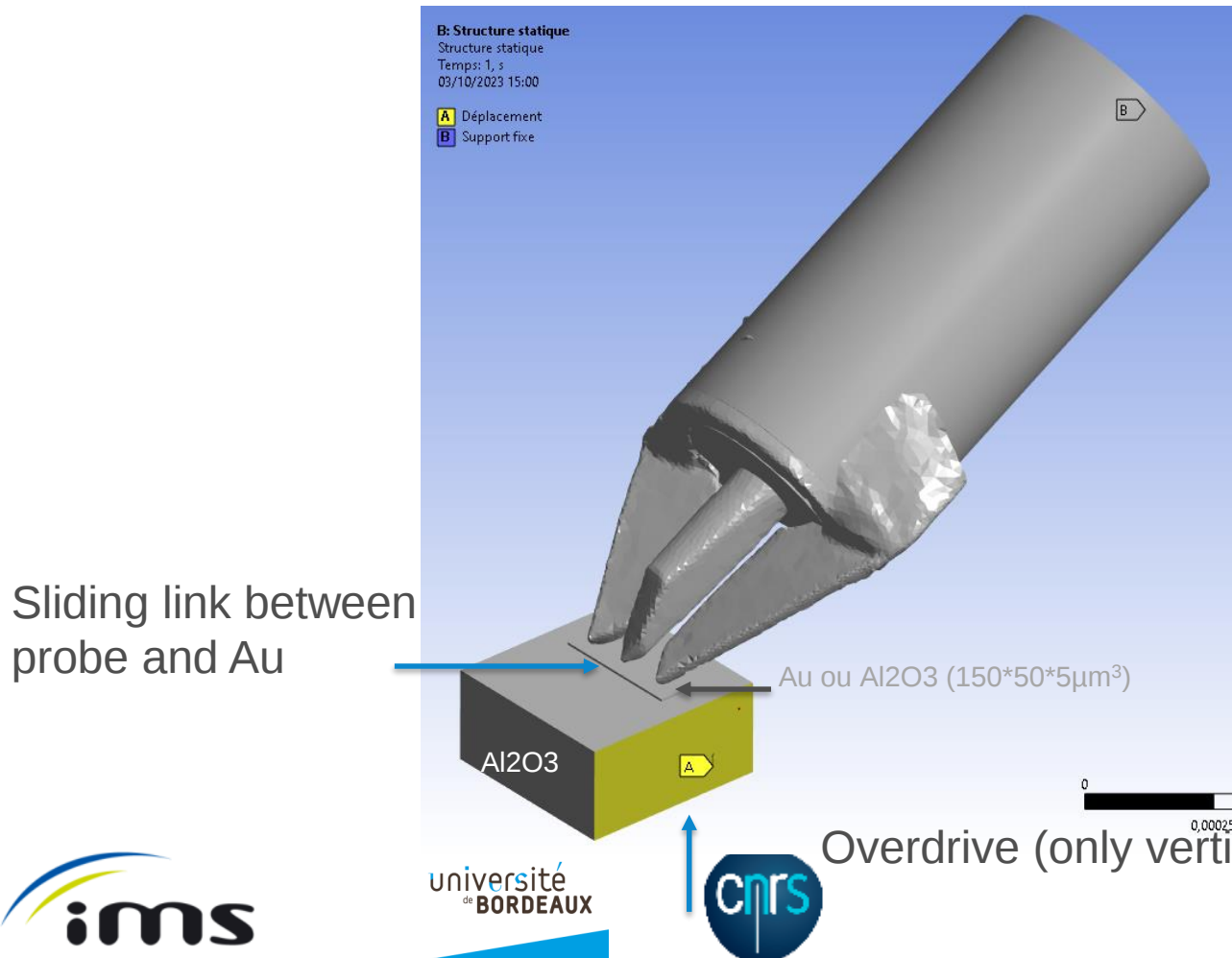
Electric field (E-field) distribution (top and side views) in the transistor-open at 220 GHz using two probe models



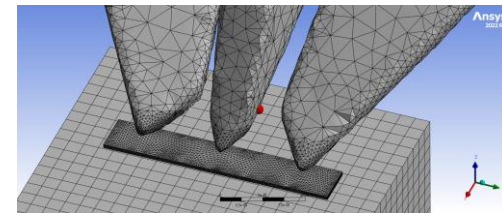
- ☐ Inter-pad distance needs to be increased
- ☐ Probes need to be downscaled to reduce the probe to substrate coupling

Mechanical Simulation: boundary condidtion

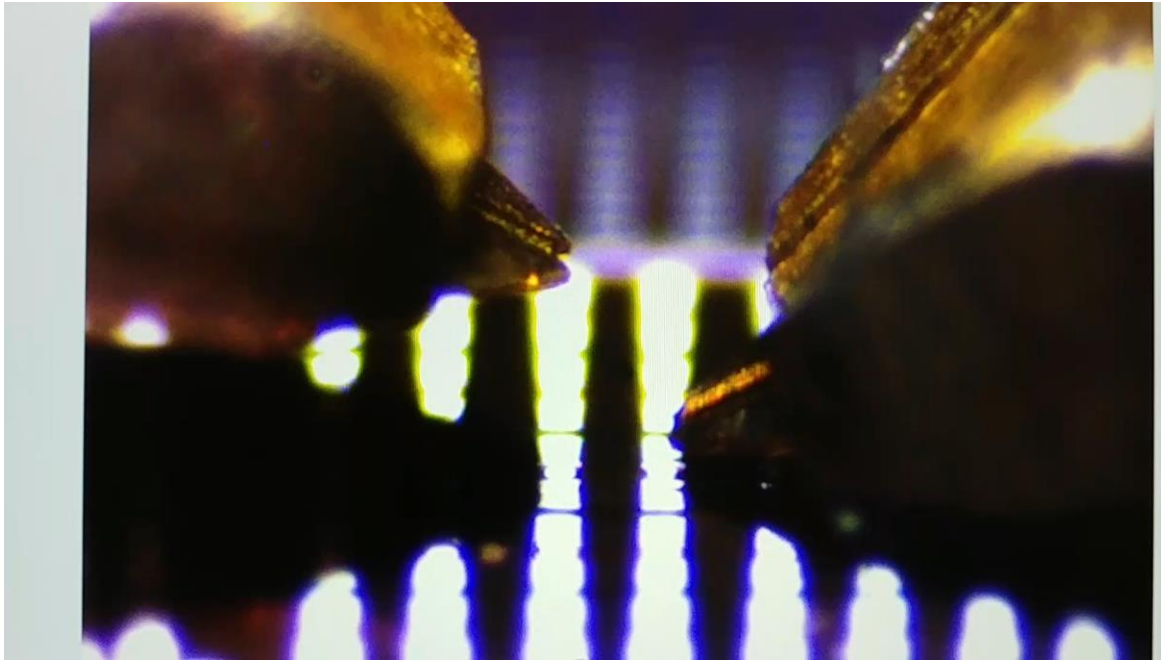
- Ex: GGB pico 110 GHz



3D model



Side view movie showing skating and probe bending: GGB 325 GHz probe

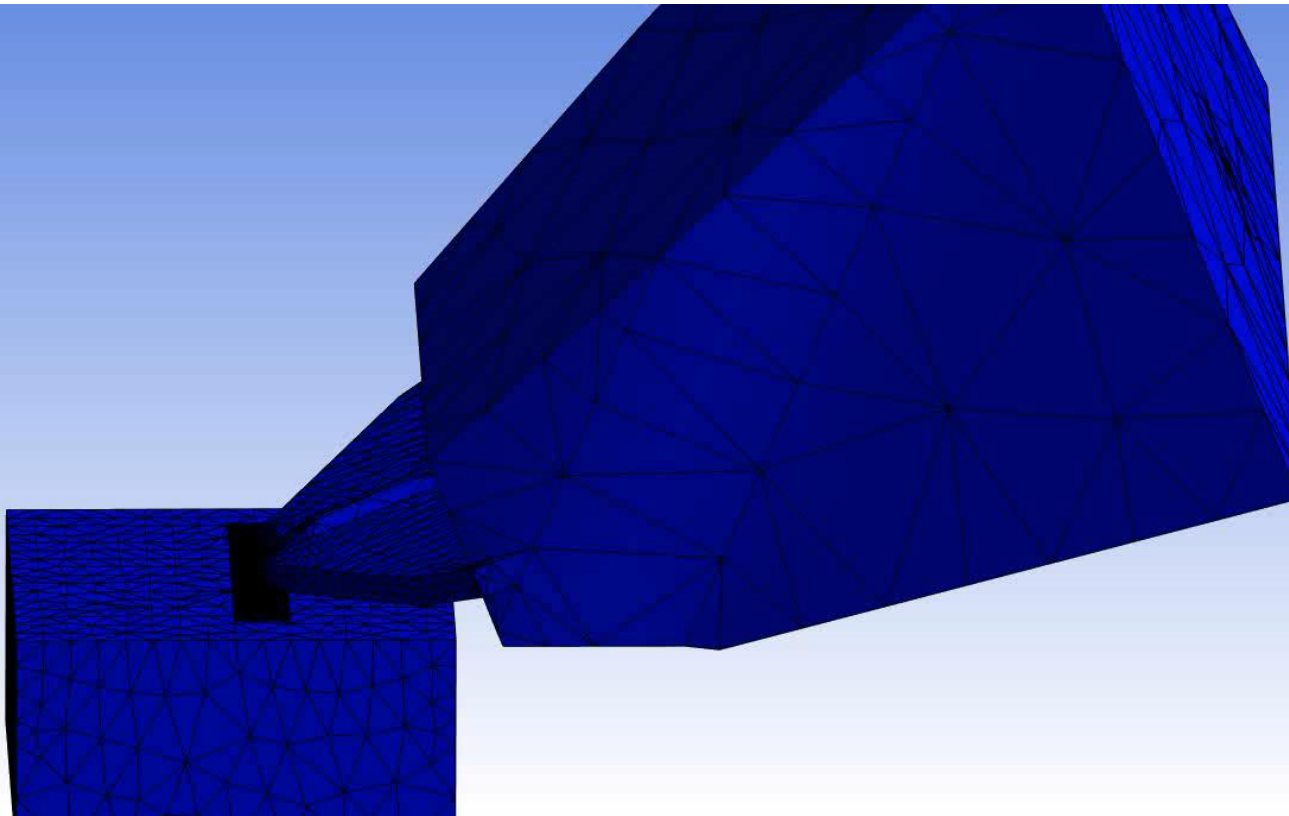


Side view simulation showing skating and probe bending: GGB 325 GHz

B: Structure statique
Déplacement directionnel 2
Type: Déplacement directionnel(Axe Z)
Unité: m
Système de coordonnées global
Temps: 1 s
09/10/2023 14:14

Ansys
2022 R2

2.8563e-5 Max
2.5303e-5
2.2043e-5
1.8783e-5
1.5523e-5
1.2263e-5
9.0028e-6
5.7427e-6
2.4826e-6
-7.7744e-7 Min



New probe design (ANR Precise)

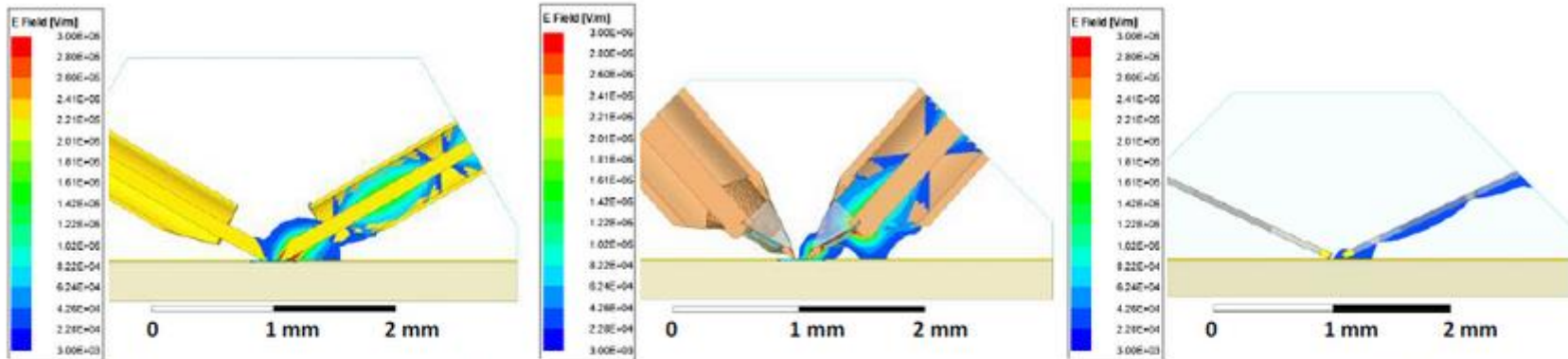


Fig. 6 Field distribution highlighting probe to substrate coupling @ 60 GHz (phase of Efield showing strongest coupling) on a load – same scale is used for each simulation (Picoprobe, Infinity, our solution).

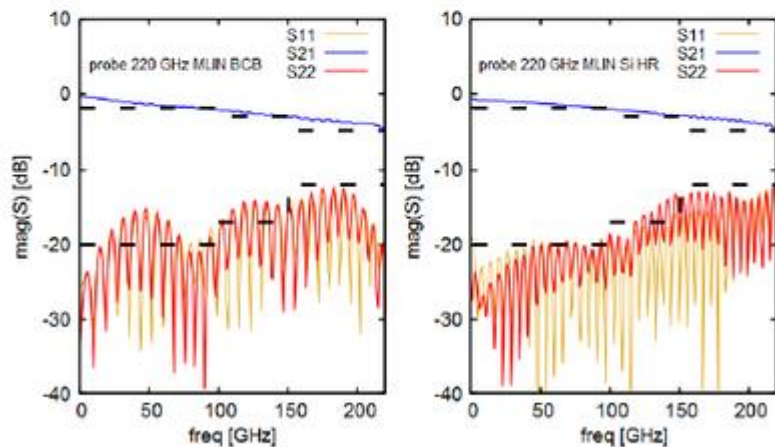


Fig. 7a : Simulation results of probe

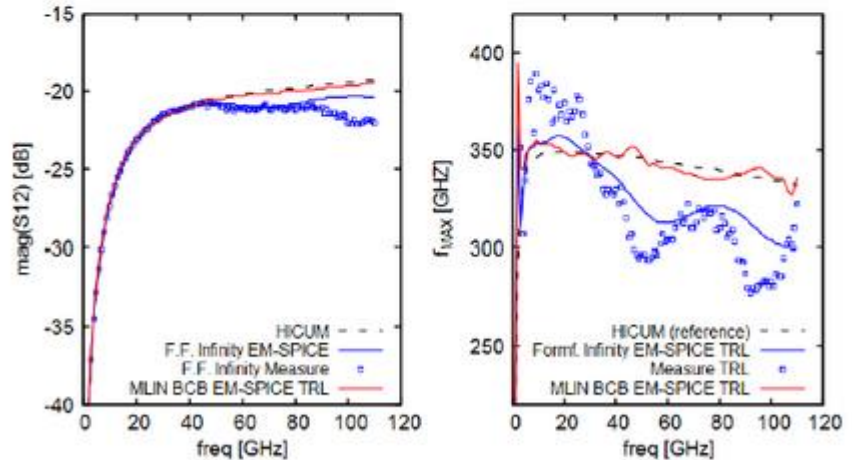


Fig. 7b: Emulation of measurement of a B55 transistor (BiCMOS 55nm) using Infinity probe and our probe

Conclusion

- Coupling is a show stopper for accurate S-parameter measurements
- Two types of coupling
 - Probe-to-probe
 - Probe-to-substrate
- Coupling can be decreased by appropriate test-structure design and layout
 - Chess-pattern of different structures on the chip
 - Appropriate distance between structures: not too dense
 - Appropriate distance between port 1 and port 2
 - etc.
- Invent new probe-tip with reduced coupling, work is on-going (results next year ?)
- Revisit 16 terms error-model: very promising results (not shown in public version)!

Acknowledgements

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